

Berry Curvature and Nonlocal Transport Characteristics of Antidot Graphene

Jie Pan,¹ Ting Zhang,^{1,2} Haijing Zhang,^{1,2} Bing Zhang,¹ Zhen Dong,¹ and Ping Sheng^{1,2,*}

¹*Department of Physics, Hong Kong University of Science and Technology,
Clear Water Bay, Kowloon, Hong Kong, China*

²*Institute for Advanced Study, Hong Kong University of Science and Technology,
Clear Water Bay, Kowloon, Hong Kong, China*

(Received 20 January 2017; revised manuscript received 2 June 2017; published 12 September 2017)

Antidot graphene denotes a monolayer of graphene structured by a periodic array of holes. Its energy dispersion is known to display a gap at the Dirac point. However, since the degeneracy between the *A* and *B* sites is preserved, antidot graphene cannot be described by the 2D massive Dirac equation, which is suitable for systems with an inherent *A/B* asymmetry. From inversion and time-reversal-symmetry considerations, antidot graphene should therefore have zero Berry curvature. In this work, we derive the effective Hamiltonian of antidot graphene from its tight-binding wave functions. The resulting Hamiltonian is a 4×4 matrix with a nonzero intervalley scattering term, which is responsible for the gap at the Dirac point. Furthermore, nonzero Berry curvature is obtained from the effective Hamiltonian, owing to the double degeneracy of the eigenfunctions. The topological manifestation is shown to be robust against randomness perturbations. Since the Berry curvature is expected to induce a transverse conductance, we have experimentally verified this feature through nonlocal transport measurements, by fabricating three antidot graphene samples with a triangular array of holes, a fixed periodicity of 150 nm, and hole diameters of 100, 80, and 60 nm. All three samples display topological nonlocal conductance, with excellent agreement with the theory predictions.

DOI: [10.1103/PhysRevX.7.031043](https://doi.org/10.1103/PhysRevX.7.031043)

Subject Areas: Graphene, Mesoscopies

I. INTRODUCTION

The advent of graphene [1–3] has attracted much attention because of its novel electronic properties, such as tunable carrier density [1–4], linear dispersion [2], valleytronics [5], etc. The additional valley degree of freedom has been experimentally investigated by breaking the sublattice symmetry, such as placing graphene on top of hexagonal boron nitride (h-BN) substrate [6] or gating bilayer graphene [7,8]. Sublattice asymmetry can be modeled by adding a mass term $m\sigma_z$ to the Weyl Hamiltonian $\hbar\nu_F\boldsymbol{\sigma} \cdot \mathbf{k}$, where $\hbar$ denotes the Planck's constant, $\boldsymbol{\sigma}$ the 2×2 Pauli matrices, ν_F the Fermi velocity, and $\mathbf{k}$ the electron wave vector. This mass term opens a gap with magnitude $2m$ at the Dirac point and induces a nonzero Berry curvature [5,9,10]. Recently, the nonzero Berry curvature was experimentally investigated by nonlocal measurements of electrical current [6–8,10–12] precisely on a system that can be described by the massive 2D Dirac Hamiltonian. The nonlocal measurement technique was originally proposed for measuring the spin Hall effect [11] and has been applied for studying the valleytronics in 2D system [6–8,12–14] like graphene.

Creating sublattice asymmetry is not the only way to open a gap in graphene. To open a gap, one can fabricate a narrow graphene nanoribbon [15–18] or make a periodic array of holes, known as antidot graphene [19,20]. The band structure [19–26] and transport properties [27–34] of antidot graphene were extensively investigated; however, the topological properties, such as Berry curvature [35], are unknown. One might expect its Berry curvature to be zero since creating holes does not break either sublattice symmetry (inversion symmetry) or time-reversal symmetry. However, in this work, we show both theoretically and experimentally that for antidot graphene, the Berry curvature can be nonzero while preserving inversion and time-reversal symmetries. This is due to the doubly degenerate eigenfunctions of antidot graphene.

To clarify the topological properties of antidot graphene, the first step is to obtain its effective Hamiltonian. Usually, the effective Hamiltonian is $\hbar\nu_F\boldsymbol{\sigma} \cdot \mathbf{k} + m\sigma_z$ [36–39], which gives the hyperbolic dispersion relation that can fit the band structure around the Dirac point well. Such a Hamiltonian is a 2×2 matrix, indicating that there is no valley mixing. The $m\sigma_z$ term models the potential difference between the two sublattice sites [39,40]. Since there is no such sublattice asymmetry in antidot graphene, it follows that the massive 2D Dirac Hamiltonian $\hbar\nu_F\boldsymbol{\sigma} \cdot \mathbf{k} + m\sigma_z$ cannot be the effective Hamiltonian for antidot graphene. In the present work, we exploited the tight-binding wave functions and band structures to derive the effective Hamiltonian for antidot

*sheng@ust.hk

Published by the American Physical Society under the terms of the [Creative Commons Attribution 4.0 International license](https://creativecommons.org/licenses/by/4.0/). Further distribution of this work must maintain attribution to the author(s) and the published article's title, journal citation, and DOI.

graphene in the vicinity of the Dirac point. The new Hamiltonian turns out to be a 4×4 matrix that preserves the sublattice symmetry as expected. A similar m term, responsible for opening a gap, appears, which describes the intervalley scattering strength. Since the eigenfunctions are doubly degenerate, nonzero Berry curvature can exist in this system while preserving both time-reversal and inversion symmetries.

A nonzero Berry curvature is expected to induce a transverse conductance [5,9,41,42]. We have experimentally verified the existence of this nonzero Berry curvature by measuring the nonlocal transverse current [6,11] and compared the results with the theory prediction. Excellent agreement is found.

A very important point about the opening of a gap in the dispersion relation and the accompanying topological properties of antidot graphene is that they are robust against randomness perturbations. This accounts for their experimental observations in plasma-etched samples.

In what follows, derivation of the effective antidot graphene Hamiltonian is described in Sec. II, followed by the evaluation of the Berry curvature in Sec. III. The measurements of nonlocal transverse electrical resistance arising from the Berry curvature, attendant with the simulation of the theory prediction, are presented in Sec. IV. Comparison between the measured data on three fabricated samples and the theory predictions is given in Sec. V. Section VI concludes with a brief summary of results.

II. EFFECTIVE HAMILTONIAN OF ANTIDOT GRAPHENE

A. Tight-binding model

Consider a triangular lattice of holes (antidots) in monolayer graphene with lattice constant L as shown in Fig. 1(a). The unit cell is hexagonal in shape with a hole at its center. To model antidot graphene, we define a dimensionless geometrical factor $\gamma = d/L$, where d denotes the hole diameter. Therefore, (L, γ) can be used to describe the antidot unit cell. The band structure and wave function can be calculated by using the tight-binding model, where the Hamiltonian is given by

$$H = -t \sum_{i,\delta} (a_i^\dagger b_{i+\delta} + \text{H.c.}). \quad (1)$$

Here $a_i^\dagger$ denotes the creation operator on the i th A sublattice site, $b_{i+\delta}$ denotes the destruction operator on the $i + \delta$ th B sublattice site, and δ includes the three nearest neighbors to site i . In Eq. (1), the summation over i goes over the whole unit cell. We apply the Bloch boundary condition at the edge of the hexagons. The band structure and wave function of the antidot graphene system can be obtained

by directly diagonalizing the Hamiltonian represented by Eq. (1). The obtained band structure is shown by the black circles in Fig. 1(c) for various γ with a fixed periodicity $L = 13$ nm. The band structure is plotted as a function of the Bloch wave vector $\mathbf{k}$, which ranges from K to Γ , then to M , and finally back to K . Here, the K , Γ , and M points are for the hole reciprocal lattices. As the antidots are arranged in the triangular lattice structure, its first Brillouin zone is hexagonal in shape, the same as the first Brillouin zone of the pristine graphene lattice. The Dirac point, i.e., the K point of the pristine graphene's reciprocal lattice, folds onto the Γ point of the hole reciprocal lattice. We can see that a gap opens at the Dirac point. Both the conduction and valence bands are doubly degenerate because of the existence of K and K' valleys. We have chosen to ignore some flat bands [43] since they correspond to localized states and do not contribute to the transport properties. At the same time, we can also obtain the wave functions $\psi = (\varphi_A, \varphi_B)^T$, which can be analyzed in the $\mathbf{k}$ domain by carrying out the Fourier transform.

B. Effective Hamiltonian

Since we wish to focus on the low-energy region, the Fourier coefficients for both φ_A and φ_B are largely determined by two components, i.e., around the K and K' . In other words,

$$\varphi_A \approx a_K(\mathbf{k})e^{i(K+\mathbf{k})\cdot\mathbf{r}} + a_{K'}(\mathbf{k})e^{i(K'+\mathbf{k})\cdot\mathbf{r}}, \quad (2a)$$

and similarly for the wave function on the B site,

$$\varphi_B \approx b_K(\mathbf{k})e^{i(K+\mathbf{k})\cdot\mathbf{r}} + b_{K'}(\mathbf{k})e^{i(K'+\mathbf{k})\cdot\mathbf{r}}. \quad (2b)$$

Therefore, the wave function can be represented by a four-dimensional vector $(a_K, a_{K'}, b_K, b_{K'})^T$, with bases $e^{i(K+\mathbf{k})\cdot\mathbf{r}}$ and $e^{i(K'+\mathbf{k})\cdot\mathbf{r}}$ for both A and B atoms, respectively. It follows that if we define

$$\Psi = (\psi_1 \quad \psi_2 \quad \psi_3 \quad \psi_4) = \begin{pmatrix} a_K^1 & a_K^2 & a_K^3 & a_K^4 \\ a_{K'}^1 & a_{K'}^2 & a_{K'}^3 & a_{K'}^4 \\ b_K^1 & b_K^2 & b_K^3 & b_K^4 \\ b_{K'}^1 & b_{K'}^2 & b_{K'}^3 & b_{K'}^4 \end{pmatrix}, \quad (3)$$

where $i = 1$ or 2 denotes the two conduction-band wave functions, and $i = 3$ or 4 denotes the two valence-band wave functions; then the effective Hamiltonian H should satisfy the following equation:

$$H\Psi = \Psi \begin{pmatrix} E_{+I} & 0 \\ 0 & E_{-I} \end{pmatrix}, \quad (4)$$

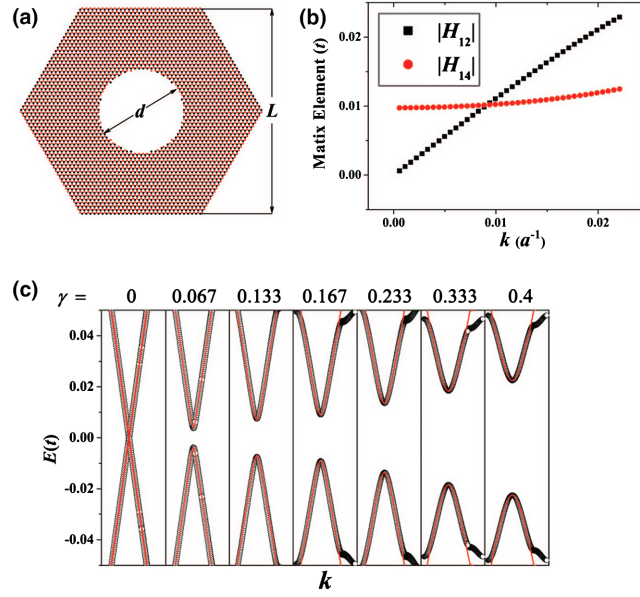


FIG. 1. (a) Antidot graphene in the tight-binding model. Red and black dots represent the carbon atoms A and B . Here, L denotes the periodicity of the antidot lattice, and d denotes the diameter of the hole. (b) The matrix element magnitude plotted as a function of Bloch wave vector $\mathbf{k}$. The term $|H_{12}|$ (black solid squares) is found to vary linearly with $k = |\mathbf{k}|$, while the intervalley scattering term $|H_{14}|$ (red solid circles) is almost a constant. (c) Band structures for various γ with a fixed periodicity $L = 13$ nm. The black circles represent the tight-binding results, and red curves stand for the dispersion relation given by the effective Hamiltonian. The Bloch wave vector $\mathbf{k}$ ranges from K to Γ , then to M, and finally back to K [here, K, Γ , and M points are for the antidot (hole) reciprocal lattice].

where E_+ and E_- denote the (degenerate) eigenvalues of the corresponding eigenfunctions and I is the 2×2 identity matrix. The effective Hamiltonian can be obtained by

$$H = \Psi \begin{pmatrix} E_+ I & 0 \\ 0 & E_- I \end{pmatrix} \Psi^\dagger. \quad (5)$$

With the eigenvalues and eigenfunctions obtained from the tight-binding calculation, we have numerically evaluated the effective Hamiltonian, which is in the form of a 4×4 matrix with only eight nonzero matrix elements:

$$H = \begin{pmatrix} 0 & H_{12} & 0 & H_{14} \\ H_{21} & 0 & H_{23} & 0 \\ 0 & H_{32} & 0 & H_{34} \\ H_{41} & 0 & H_{43} & 0 \end{pmatrix}. \quad (6)$$

We have found that $|H_{12}| = |H_{21}| = |H_{34}| = |H_{43}|$ and $|H_{14}| = |H_{23}| = |H_{32}| = |H_{41}|$. In Fig. 1(b), we present the results of the matrix element as a function of $\mathbf{k}$ around the Γ point of the antidot lattice. It is seen that $|H_{12}|$ is linear in $\mathbf{k}$, while $|H_{14}|$ is almost a constant. The details of H_{12} 's $\mathbf{k}$ dependence (i.e., as a function of k_x and k_y) can be obtained by setting $\mathbf{k}$ along the x and y directions. It is found that the Hamiltonian can be expressed as

$$H = \begin{pmatrix} 0 & \hbar v(k_x - ik_y) & 0 & m \\ \hbar v(k_x + ik_y) & 0 & m & 0 \\ 0 & m & 0 & \hbar v(-k_x - ik_y) \\ m & 0 & \hbar v(-k_x + ik_y) & 0 \end{pmatrix}. \quad (7)$$

Therefore, the effective Hamiltonian consists of two 2×2 matrices, $\hbar v \boldsymbol{\sigma} \cdot \mathbf{p}$ and $-\hbar v \boldsymbol{\sigma}^* \cdot \mathbf{p}$, along the diagonal and four antidiagonal m terms [44]. The two diagonal matrices are seen to originate from the pristine graphene Hamiltonian, which can be easily verified by doing Taylor expansion around K and K' points of pristine

graphene. Note that the velocity v here is not necessarily the same as v_F ($c/300$) in pristine graphene. In antidot graphene, it is a function of the geometric factor γ . The four antidiagonal m terms couple the K and K' valleys; hence, they imply intervalley scatterings, which can arise from the atomically sharp edges of the antidots. We find the

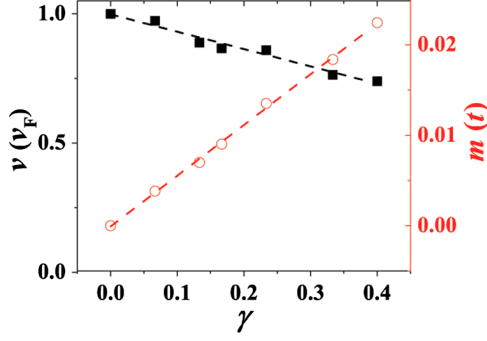


FIG. 2. Effective velocity v and intervalley scattering strength m are plotted as a function of the geometric factor γ . The calculated results on velocity v (in units of v_F) are shown as black solid squares, and those for m (in units of t) are shown as red open circles. These parameters are obtained for a fixed periodicity $L = 13$ nm. The dashed curves are linear fittings.

intervalley scattering strength to have a very weak k^2 dependence, which is ignored here since we focus only on the low-energy regime. Hence, the intervalley scattering strength is characterized by a constant m . The effective Hamiltonian yields a dispersion relation $E = \pm\sqrt{\hbar^2 v^2 k^2 + m^2} = \pm\epsilon$, where both the conduction and valence bands are doubly degenerate. This dispersion relation, which is shown as red curves in Fig. 1(c), can fit the numerically obtained band structures very well, thereby confirming this effective Hamiltonian to be relatively accurate for modeling the antidot graphene system in the vicinity of the Γ point (of the antidot lattice).

The values of the velocity, v and m , depend on the geometry of antidot graphene. The values evaluated from the tight-binding calculations are summarized in Fig. 2. For a fixed periodicity L , the effective velocity v (black solid squares) decreases with increasing γ , while the gap ($2m$) increases with increasing γ . A decrease of the Fermi velocity associated with the gap opening can also be found in Ref. [45]. It can be plausibly understood as due to the narrowing of the “neck” region of the passage channels with increasing γ . We can linearly fit m and v as a function of γ , which are shown as dashed curves in Fig. 2:

$$\begin{cases} v = (1 - 0.67\gamma)v_F \\ m = 0.056\gamma t \cdot \frac{13 \text{ nm}}{L} \end{cases} \quad (8)$$

The term m scales with the inverse of the periodicity, i.e., varying as $1/L$, which is in accordance with previous numerical results [19,46]. For our experimental samples, we have a fixed $L = 150$ nm and $\gamma = 2/3$ (sample A), $8/15$ (sample B), and $2/5$ (sample C). The corresponding gap ($2m$) is around 20 meV, and the effective velocity v is about $0.55v_F$; hence, $m/\hbar v = 0.03 \text{ nm}^{-1}$ for sample A. Values of m and v for samples B and C can be similarly deduced from Eq. (8).

C. Uniqueness of the effective Hamiltonian

Since the bands are doubly degenerate, the two wave functions $(\psi_1 \ \psi_2)$ at the same energy can form a linear combination $(\psi'_1 \ \psi'_2)$, which would be an equally valid choice. The question is whether different choices of the wave functions can result in a different effective Hamiltonian. To prove the uniqueness of the effective Hamiltonian, we recognize the fact that the wave functions must transform into each other via the unitary matrix $U_{\pm}$ for both the conduction and valence bands. In other words,

$$\begin{cases} (\psi'_1 \ \psi'_2) = (\psi_1 \ \psi_2)U_+ \\ (\psi'_3 \ \psi'_4) = (\psi_3 \ \psi_4)U_- \end{cases} \quad (9)$$

Let H' be the alternative effective Hamiltonian and let $\Psi' = (\psi'_1 \ \psi'_2 \ \psi'_3 \ \psi'_4)$. Based on Eq. (5), we have

$$H' = \Psi' \begin{pmatrix} E_+ I & 0 \\ 0 & E_- I \end{pmatrix} \Psi'^{\dagger}. \quad (10)$$

Here, $\Psi' = \Psi \begin{pmatrix} U_+ & 0 \\ 0 & U_- \end{pmatrix}$. We can simplify H' as

$$\begin{aligned} H' &= \Psi \begin{pmatrix} U_+ & 0 \\ 0 & U_- \end{pmatrix} \begin{pmatrix} E_+ I & 0 \\ 0 & E_- I \end{pmatrix} \begin{pmatrix} U_+ & 0 \\ 0 & U_- \end{pmatrix}^{\dagger} \Psi^{\dagger} \\ &= \Psi \begin{pmatrix} E_+ I & 0 \\ 0 & E_- I \end{pmatrix} \begin{pmatrix} U_+ & 0 \\ 0 & U_- \end{pmatrix} \begin{pmatrix} U_+ & 0 \\ 0 & U_- \end{pmatrix}^{\dagger} \Psi^{\dagger} \\ &= H. \end{aligned} \quad (11)$$

Therefore, we can conclude that the effective Hamiltonian obtained above is unique; i.e., it would remain the same regardless of the choice of wave functions.

III. NONZERO BERRY CURVATURE

A. Symmetry analysis

The nonzero term m mixes the K and K' valleys whose Berry curvatures have opposite signs. Hence, one may wonder whether there is net nonzero Berry curvature with this valley mixing. It is noted that both time-reversal and inversion symmetries are preserved in this system; however, that does not guarantee a zero Berry curvature [9,41,42,47,48]. We start the symmetry analysis with the eigenvectors of the conduction band, obtained directly from the effective Hamiltonian, Eq. (7),

$$\begin{cases} \psi_1(\mathbf{k}) = \left(\frac{ke^{-i\theta}}{\sqrt{\epsilon+m}} \ \sqrt{\epsilon+m} \ \sqrt{\epsilon+m} \ -\frac{ke^{-i\theta}}{\sqrt{\epsilon+m}} \right)^T / 2\sqrt{\epsilon} \\ \psi_2(\mathbf{k}) = \left(-\frac{ke^{-i\theta}}{\sqrt{\epsilon-m}} \ -\sqrt{\epsilon-m} \ \sqrt{\epsilon-m} \ -\frac{ke^{-i\theta}}{\sqrt{\epsilon-m}} \right)^T / 2\sqrt{\epsilon} \end{cases}, \quad (12)$$

where $\theta = \arctan(k_y/k_x)$ denotes the direction of the wave vector $\mathbf{k}$. Since there is double degeneracy for the

conduction band, any linear combination of ψ_1 and ψ_2 is also an eigenwavefunction of the effective Hamiltonian, Eq. (7). In Eq. (12), the eigenwavefunctions are chosen so that the Berry curvature matrix is diagonalized, as shown in Sec. III B. Under time-reversal transformation (see Appendix A),

$$T\psi_2(\mathbf{k}) = \psi_2(-\mathbf{k})^* = e^{i\theta}\psi_1(\mathbf{k}), \quad (13)$$

from which we conclude that the Berry curvature must obey (see Appendix B)

$$\Omega_2(-\mathbf{k}) = -\Omega_1(\mathbf{k}), \quad (14)$$

where the subscript denotes the respective wave function [Eq. (12)] from which the Berry curvature is evaluated. Similarly, for the inversion symmetry, we have $\Omega_1(-\mathbf{k}) = \Omega_1(\mathbf{k})$ and $\Omega_2(-\mathbf{k}) = \Omega_2(\mathbf{k})$. Combining both the time-reversal and inversion symmetries, we find that the symmetry conditions only require

$$\Omega_1(\mathbf{k}) + \Omega_2(\mathbf{k}) = 0. \quad (15)$$

Hence, the Berry curvature for each band is not necessarily zero. Below, we can see that, for our degenerate system, the Berry curvature is indeed nonzero.

If we focus on the region near the Γ point (of the hole lattices), i.e., $|\mathbf{k}| \sim 0$, the eigenvectors from Eq. (12) can be simplified as

$$\begin{cases} \psi_1 \approx (0 & 1 & 1 & 0)^T / \sqrt{2} = |K'\rangle_A + |K\rangle_B \\ \psi_2 \approx (-1 & 0 & 0 & -1)^T / \sqrt{2} = |K\rangle_A + |K'\rangle_B \end{cases}. \quad (16)$$

Equation (16) clearly shows the mixing behavior between the K and K' valleys. For instance, for ψ_1 , the wave function of atom A comes from the K' valley, while for atom B , it comes from the K valley. However, if we assume that there is a long-range potential V (such as the Coulomb potential of the charged impurity), the scattering matrix element should be

$$\langle \psi_1 | V | \psi_2 \rangle = (\langle K | V | K' \rangle)_A + (\langle K' | V | K \rangle)_B \sim 0. \quad (17)$$

In other words, the long-range disorders cannot scatter ψ_1 to ψ_2 . Note that the intervalley scattering is already taken into account in the Hamiltonian and its relevant wave functions.

B. Calculation of the Berry curvature

Since the 4×4 matrix describes a doubly degenerate system, the Berry curvature for either the conduction or valence band is essentially a 2×2 matrix, which is defined as [9,41,42,47–49]

$$\Omega = \partial_{k_x} A_y - \partial_{k_y} A_x - i[A_x, A_y]. \quad (18)$$

Here, the Berry connection A_α is a matrix, whose matrix elements are defined as $(A_\alpha)_{mn} = i\langle u_m | \partial_{k_\alpha} | u_n \rangle$, where $u_{m(n)}$ denotes the periodic part of the wave function. We can see that the first two terms originate from the non-degenerate case, while the last term is the correction term due to degeneracy [9,42,47–49]. If there is no degeneracy, A_α is a number instead of a matrix, making $[A_x, A_y]$ zero.

The calculation of the Berry connection requires information from the periodic parts of the wave function denoted by $u_{m(n)}$. We can derive the expression for u based on Eqs. (2a) and (2b), i.e., $u \approx (a_K(\mathbf{k})e^{i\mathbf{K}\cdot\mathbf{r}} + a_{K'}(\mathbf{k})e^{i\mathbf{K}'\cdot\mathbf{r}} b_K(\mathbf{k})e^{i\mathbf{K}\cdot\mathbf{r}} + b_{K'}(\mathbf{k})e^{i\mathbf{K}'\cdot\mathbf{r}})^T$. Since the integration of $\exp[i(\mathbf{K} - \mathbf{K}') \cdot \mathbf{r}]$ over the unit cell is zero, we obtain $(A_\alpha)_{mn} = i\langle u_m | \partial_{k_\alpha} | u_n \rangle = i\langle \psi_m | \partial_{k_\alpha} | \psi_n \rangle$, where $\psi_{m(n)}$ are the eigenvectors of the effective Hamiltonian [Eq. (12)]. Hence, by substituting Eq. (12) into Eq. (18), we find that the Berry curvature is given by

$$\Omega = \begin{pmatrix} \frac{m/\hbar v}{2[(m/\hbar v)^2 + k^2]^{3/2}} & 0 \\ 0 & -\frac{m/\hbar v}{2[(m/\hbar v)^2 + k^2]^{3/2}} \end{pmatrix}. \quad (19)$$

It is seen that the Berry curvature matrix is nonzero only for the diagonal terms. It is also noted that the matrix element Ω_{11} is the same as the Berry curvature of the massive Dirac Hamiltonian [5], where m characterizes the local potential difference between the carbon atoms A and B . The Berry curvature is determined solely by one parameter, i.e., $m/\hbar v$. In Fig. 3, we summarize the Berry curvature for different geometric parameters γ . It peaks at $k = 0$ and decays as k deviates from 0. The Berry curvature can also be obtained through tight-binding calculations [48]. We found that near the Γ point of the antidot lattice,

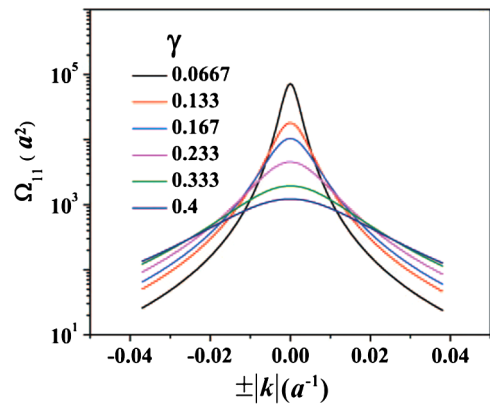


FIG. 3. Berry curvature matrix element Ω_{11} calculated as a function of wave vector $\mathbf{k}$ for various values of the geometric factor γ [based on Eq. (19)]. The parameter $m/\hbar v$ can be obtained from the tight-binding calculations, where the periodicity L is fixed at 13 nm. Here a denotes the carbon-carbon atomic separation ($= 1.42 \text{ \AA}$).

Eq. (19) agrees well with the Berry curvature obtained through tight-binding calculations. Away from the Γ point, there can be differences between the two. It is also to be noted that by integrating the Berry curvature calculated by the tight-binding model over the first Brillouin zone, we obtain a Berry phase of 2π . Therefore, the effective Hamiltonian, Eq. (7), and the Berry curvature, Eq. (19), can well describe the antidot graphene system only at the low-Fermi-energy region.

C. Robustness against randomness perturbations

From the derived effective Hamiltonian and the related analysis, it should be clear that the gap opening in the antidot graphene is due to the folding of the K and K' points [26] of the reciprocal carbon lattice, onto the Γ point of the hole reciprocal lattice. Specifically, K and K' (of carbon lattice) are located at $(\pm 4\pi/(3\sqrt{3}a), 0)$, where a is the carbon-carbon atomic separation. If the periodicity of holes is given by $3Na$, where N is an integer, then the primitive vector of the reciprocal hole lattice is $4\pi/(3\sqrt{3}Na) \cdot (1/2, \pm\sqrt{3}/2)$. We can see that K and K' can be folded onto the Γ point.

In the above context of a perfect antidot lattice, it was pointed out in Ref. [22] that if the hole lattice is rotated by $\pi/6$, which is denoted the “rotated triangular lattice,” and, in addition, if the periodicity of the hole lattice is $\sqrt{3}Na$ so that the primitive vector of the reciprocal hole lattice is $4\pi/(3Na) \cdot (\sqrt{3}/2, \pm 1/2)$, with $N \neq 3n$ (n being an integer), then K and K' valleys are not coupled; therefore, there can be no band gap. These conclusions were numerically verified in Ref. [22], where the results were explained by using the Clar sextet theory. Below, we show that such cases are unstable against small-scale randomness perturbations on the edge of the holes. Such randomness would be difficult to avoid in the oxygen etching of the antidot pattern. It is demonstrated that once there is atomic-scale randomness on the edges of the holes, then the full band gap is restored; the magnitude of the band gap in such cases is fairly accurately predicted by Eq. (8) from the geometric parameter γ .

The conclusion from such randomness perturbation analysis, shown below, is that the results obtain from Sec. II are generally applicable to the experimentally fabricated antidot samples.

To determine whether the antidot sample is gapped or gapless, we calculate its conductance as a function of Fermi energy. If there is a zero conductance plateau, then there is a band gap; otherwise, it is a gapless system. The conductance of the antidot graphene system can be well simulated by the open-source package KWANT [50], which can calculate the electronic transport property based on the tight-binding models. We have carried out simulations for the three different cases as follows.

(a) *Lattice A*—This is the “triangular lattice structure,” which is what we have focused on in Sec. II. In this case, K and K' can always be folded onto the Γ point

of the hole reciprocal lattice; i.e., a gap is expected. Here, the periodicity is fixed at $L = 24a$, with $\gamma = 0.2$.

(b) *Lattice B*—This is the “rotated triangular lattice structure” [22], which is predicted to have no gap. The periodicity in this case is fixed at $L = 14\sqrt{3}a$ with the same $\gamma = 0.2$ as in (a). The value of the periodicity, $L = 14\sqrt{3}a (\approx 24.2a)$, is chosen so that K and K' cannot be folded onto the same Γ point. A gapless system is expected; i.e., the conductance should exhibit no zero-conductance region.

(c) *Lattice C*—This is the same as Lattice B but modified with atomic-scale randomness at the edges of the holes. We assume that the hole radius is angular dependent; i.e., $r_n(\theta) = r \cdot (1 + f_n(\theta))$, where n refers to the n th hole. The term $f_n(\theta)$ is defined as $f_n(\theta) \equiv \sum_m a_{nm} \cos(m\theta + \varphi_{nm})$, where the summation of m goes from 1 to 5. In the simulations, we have randomly chosen $a_{nm} \in (0, 0.06)$, $\varphi_{nm} \in (0, 2\pi)$ for each hole.

The whole system for transport simulations is shown in Fig. 4(a). We can see that there are 10 holes in the width

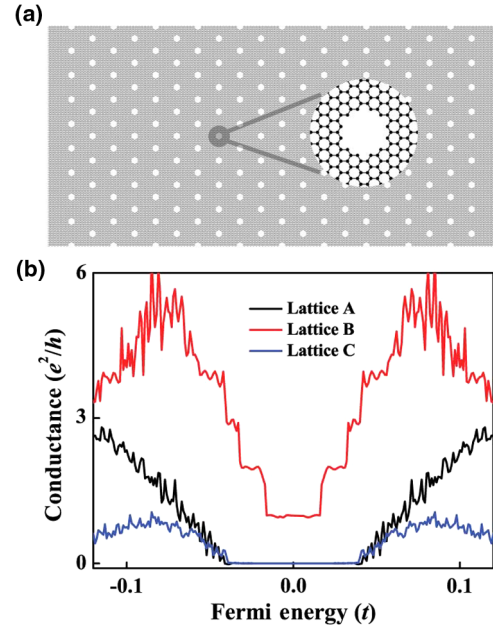


FIG. 4. (a) Schematic illustration of an antidot graphene lattice (Lattice B) for calculating the conductance as a function of Fermi energy. The system contains 20 holes in the x direction and 10 holes in the y direction. The inset is a zoom-in image of the antidot lattice with a hole. (b) Calculated conductance plotted as a function of Fermi energy. The black curve represents the conductance of Lattice A, where the zero-conductance plateau indicates the band gap of this system. For Lattice B, the red curve exhibits no zero-conductance regions, implying that there is no band gap. Lattice C differs from Lattice B only at the edges of the holes, where we have added atomic-scale randomness. Ten different randomness profiles were calculated, and the blue curve represents the ensemble-averaged conductance. It is seen that a band gap reappears, and the magnitude of this band gap is the same as that of Lattice A, implying that the transport gap in Lattice C has the same origin as that in Lattice A, i.e., from K to K' intervalley scatterings.

direction and 20 holes in the length direction. The inset image is a zoom-in for a hole in Lattice B, i.e., “the rotated triangular lattice structure.” The conductances as a function of Fermi energy of the three cases are summarized in Fig. 4(b). For Lattice A, the conductance is plotted as the black curve, where a zero conductance plateau is observed as expected. For Lattice B, the conductance does not drop to zero at zero Fermi energy, shown by the red curve. This clearly implies that there is no band gap for Lattice B, as predicted. For the third case, we introduced atomic-scale randomness into Lattice B. In this case, we have calculated 10 different randomness profiles, and the blue curve in Fig. 4(b) is the averaged conductance. It is clearly seen that with randomness, the full band gap reappears. The magnitude of the band gap in the third case is exactly the same as that of Lattice A, around $0.08t$. With the appropriate parameter values of $L = 24a$ and $\gamma = 0.2$, Eq. (8) predicts a band gap around $0.084t$, which is consistent with the conductance simulation results.

There is a simple explanation for the reappearance of the gap when the atomic-scale perturbations were added. In this case, small-scale randomness in real space implies scatterers with large momentum transfers in the reciprocal space, i.e., short-range scatterers. That means intervalley scatterings are the inevitable consequences of introducing atomic-scale randomness, and the opening of the gap is the result. There is also a simple heuristic explanation for why the obtained gap size depends on the geometric parameter $\gamma/L = d/L^2$ as given by Eq. (8). The K to K' scattering strength is given by $\langle K|V_{sr}|K' \rangle$, where V_{sr} denotes the effective short-range disorder potential. Here, V_{sr} must be proportional to the number of sites at the edges of the holes, which is proportional to the circumference of the hole; hence, $V_{sr} \sim nd$, where n is the number of holes. The wave amplitudes of $|K \rangle$ and $|K' \rangle$ must each be normalized in the sample area S , which means $|K \rangle$ and $|K' \rangle$ must each be proportional to $1/\sqrt{S}$. Combining these two facts, we get $\langle K|V_{sr}|K' \rangle \propto nd/S \sim d/L^2$, as $S \propto nL^2$. However, such an argument cannot yield the accurate value of the gap, which must be determined numerically.

From this perspective, the existence of a gap in antidot graphene is almost inevitable for the experimentally fabricated antidot samples by using plasma etching. The no-gap state is very precarious since its existence requires the very precise periodicity, with no atomic-scale randomness allowed.

D. Energy splitting of the eigenfunctions

Accompanying the introduction of edge randomness into the antidot graphene is the splitting of the originally doubly degenerate eigenfunctions as in the case of Lattice A above. Below, we first quantify such splittings and then show in the subsequent section that the topological manifestation of antidot graphene is not affected by such splittings.

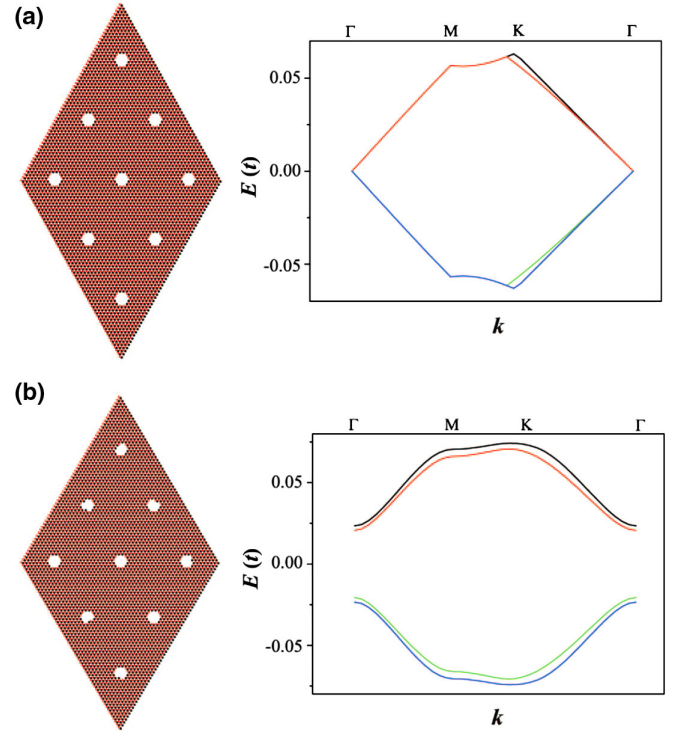


FIG. 5. Supercells and the simulated band structures. Each supercell comprises nine unit cells, whose hole periodicity is given by $19\sqrt{3}a$. In diagram (a), we have an antidot lattice without any randomness; i.e., periodicity is accurate down to the atomic scale. We can see that there is no band gap, as predicted. (b) Antidot lattice with randomness. For this case, the band gap reappears, accompanied by a small energy splitting for both the conduction and valence bands. In other words, the states in the conduction and valence bands are quasidegenerate.

We have calculated the band structure of antidot graphene with randomness by using the supercell approach in which each supercell comprised several unit cells with randomness introduced at the hole edges. The Bloch boundary condition was imposed at the boundary of supercells. The periodicity of the unit cell is set to $19\sqrt{3}a$ so that there is no K to K' coupling in the perfect antidot lattice case. For the supercell, we consider nine holes as shown in Fig. 5. The periodicity of the supercell is $19\sqrt{3}a \times 3$. For the band-structure data presented in Fig. 5, we have removed the flat bands. If $f(\theta) = 0$, i.e., no randomness, we can see that there is no band gap, as shown in Fig. 5(a). For Fig. 5(b), we consider the same case as in Fig. 5(a) but with atomic-scale randomness. It is noted that there is a tiny energy splitting of the originally doubly degenerate eigenfunctions, accompanying the appearance of the band gap. Hence, the conduction (valence) bands become quasidegenerate. In Fig. 5(b), the size of the gap is around $0.05t$, which is close to the prediction by Eq. (8), which gives a gap around $0.052t$.

In the presence of the randomness perturbation, the effective Hamiltonian can be numerically evaluated to be

$$\begin{pmatrix} \hbar\nu\boldsymbol{\sigma} \cdot (\mathbf{k} + \mathbf{c}) & m\sigma_x \\ m\sigma_x & -\hbar\nu\boldsymbol{\sigma} \cdot (\mathbf{k} - \mathbf{c}) \end{pmatrix}, \quad (20)$$

where $\mathbf{c} \approx \mathbf{c}_0 + \mathbf{c}_1\mathbf{k} + \mathbf{c}_2\mathbf{k}^2 + O(k^3)$. This nonzero $\mathbf{c}$ turns out to be responsible for the energy splitting of the eigenfunctions in the conduction (valence) band. In fact, one can easily evaluate the dispersion relation from the above effective Hamiltonian to give $E(\mathbf{k}) = \pm\sqrt{\hbar^2\nu^2k^2 + m^2 + \hbar^2\nu^2|\mathbf{c}|^2 \pm 2\hbar\nu\sqrt{m^2|\mathbf{c}|^2 + (\hbar\nu\mathbf{k} \cdot \mathbf{c})^2}}$, which indicates an energy splitting in the eigenfunctions of both the conduction and valence bands. This splitting turns out to be on the order of $0.1m$. Hence, both the conduction and valence bands can be regarded as quasidegenerate.

One may wonder what effect this splitting might have on the topological characteristics of antidot graphene. Below, we show that the topological manifestation is not changed from the case when the eigenfunctions are doubly degenerate.

E. Effect of the Berry curvature under an applied electric field

Berry curvature is well known to affect the electronic transport in the presence of an electric field. This is a physical manifestation of Berry curvature. In the present case, the Berry curvature Ω is a 2×2 matrix since the conduction and valence bands are (quasi-) double degenerate. Let (φ_1, φ_2) denote the two quasidegenerate states; an arbitrary initial state ψ is expressible as a linear superposition of (φ_1, φ_2) , i.e., $\psi = \eta_1\varphi_1 + \eta_2\varphi_2$, where $\eta_{1,2}$ are the coefficients satisfying $|\eta_1|^2 + |\eta_2|^2 = 1$. It would be convenient to express ψ in a vector form $\boldsymbol{\eta} = (\eta_1 \ \eta_2)^T$. In the presence of an applied electric field, the electronic velocity transverse to the electric field direction is given by [47]

$$v_x = (eE_y/\hbar) \cdot \boldsymbol{\eta}^\dagger \Omega \boldsymbol{\eta}, \quad (21a)$$

where E_y is the external electric field. Based on the tight-binding model [48], we have numerically calculated the Ω matrix by using the supercell with randomness. It turns out that the off-diagonal terms of Ω are nonzero. For simplicity in evaluating the effect of the Berry curvature under an electric field, we choose to diagonalize Ω by changing to a new basis. If the diagonalization matrix is U , we have $\Omega' = U\Omega U^\dagger$, where $\Omega' = \begin{pmatrix} \Omega_{11} & 0 \\ 0 & \Omega_{22} \end{pmatrix}$. It follows that Eq. (21a) can be simplified as

$$v_x = (eE_y/\hbar) \cdot (\boldsymbol{\eta}')^\dagger \Omega' \boldsymbol{\eta}', \quad (21b)$$

where $\boldsymbol{\eta}' \equiv U\boldsymbol{\eta} = (\eta'_1 \ \eta'_2)^T$ and $|\eta'_1|^2 + |\eta'_2|^2 = 1$. The values of Ω_{11} and Ω_{22} in the first Brillouin zone are summarized in the inset of Fig. 6. We can see that Ω_{11} and Ω_{22} have opposite signs, i.e., $\Omega_{22} = -\Omega_{11}$, and their

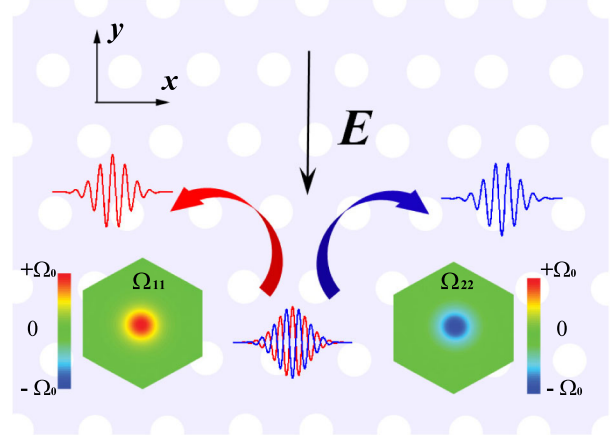


FIG. 6. Cartoon image illustrating different wave states' evolution under an external electric field under the influence of the Berry curvature. The value of the Berry curvature is shown in the color scale, plotted in the first Brillouin zone of the antidot graphene. The bottom left (right) shows the value of the diagonal matrix term Ω_{11} (Ω_{22}), with the peak value at the Γ point of the antidot reciprocal lattice. The red wave represents the case of $|\eta'_1|^2 > 1/2$; it travels to the left as $v_x < 0$. The blue wave represents the case of $|\eta'_1|^2 < 1/2$; it travels to the right.

values are very close to those shown in Eq. (19). From Eq. (21b), we have $v_x = (eE_y/\hbar) \cdot (|\eta'_1|^2 - |\eta'_2|^2)\Omega_{11}$. This result means that when $|\eta'_1|^2 > 1/2$, the electronic wave tends to go left as E_y is negative (applied in the minus y direction), as illustrated by the red wave in Fig. 6. If we focus on the states that flow leftwards, the average transverse velocity is given by

$$\bar{v}_x = \frac{eE_y}{\hbar} \cdot \frac{\sum_{|\eta'_1|^2 > 1/2} (\boldsymbol{\eta}')^\dagger \Omega' \boldsymbol{\eta}'}{\sum_{|\eta'_1|^2 > 1/2} (\boldsymbol{\eta}')^\dagger \boldsymbol{\eta}'}, \quad (22)$$

where the denominator is the normalization factor. The summation can be carried out by integration. By assuming that $\eta'_1 = |\eta'_1| \exp(i\beta_1)$ and $\eta'_2 = \sqrt{1 - |\eta'_1|^2} \exp(i\beta_2)$, where $1/\sqrt{2} \leq |\eta'_1| < 1$, $0 \leq \beta_{1,2} < 2\pi$, it follows that $\sum_{|\eta'_1|^2 > 1/2} = \int_{1/\sqrt{2}}^1 |\eta'_1| \cdot d|\eta'_1| \int_0^{2\pi} d\beta_1 \int_0^{2\pi} d\beta_2$. Equation (22) can be easily evaluated, and the average velocity turns out to be $\bar{v}_x = (eE_y/\hbar) \cdot (\Omega_{11}/2)$. For the range $|\eta'_1|^2 < 1/2$, the average transverse velocity is $\bar{v}_x = -(eE_y/\hbar) \cdot (\Omega_{11}/2)$. Hence, the effective Berry curvature for inducing the transverse current is half of the diagonal matrix element, i.e., $\pm\Omega_{11}/2$.

In the above, it can be seen that independent of whether the states are doubly degenerate or quasidegenerate, the Berry curvature in antidot graphene has the same physical manifestation. The atomic-scale randomness at the edge of the holes, in fact, makes the topological effect more robust, i.e., insensitive to the relative rotation of the hole lattice vs the underlying graphene lattice, as well as to the precise

values of the hole lattice constant. This predicted “topological Hall effect” is interesting, and we show experimentally, in the following section, by fabricating and measuring three samples with different geometric parameter values, that the topological current indeed exists in antidot graphene.

IV. MEASUREMENT OF NONLOCAL RESISTANCE IN ANTIDOT GRAPHENE

A. Sample and experimental setup

To experimentally check the nonzero Berry curvature, we have fabricated the antidot graphene samples and studied their electronic transport properties by exploiting the nonlocal measurements. The single-layer graphene was obtained by mechanical exfoliation and transferred onto a silicon wafer with a SiO_2 thickness of 285 nm. The periodic antidots are patterned by e-beam lithography, followed by oxygen plasma etching. The whole sample was etched into standard Hall bar geometry, shown as the cartoon image in Figs. 7(a) and 7(b), where the blue region is the antidot graphene, while the grey parts denote the electrodes (10 nm Ti/60 nm Au). The geometric parameters are set as $d_1 = 2 \mu\text{m}$, $d_2 = 4 \mu\text{m}$, and $W = 2 \mu\text{m}$. For the antidot lattice, we have fabricated three different samples. All samples have periodicity fixed at $L = 150 \text{ nm}$, while the

hole diameters were designed to be $d = 100$ (sample A), 80 (sample B), and 60 (sample C) nm. Scanning-electron-microscope images are shown in the inset of Fig. 7(c) for sample A, and in Fig. 14 for sample B (upper panel) and sample C (bottom panel). All measurements were conducted in PPMS (Quantum Design) after *in situ* annealing at 390 K for 2 hours. We focus on analyzing the data from sample A. Similar results for samples B and C are summarized in Fig. 14.

B. Nonlocal measurements

The nonzero Berry curvature in antidot graphene can be experimentally verified by applying the nonlocal measurements, and the setup is shown in Fig. 7(a). By applying a current I through one pair of Hall electrodes and recording the voltage drop V_{nl} between another nearby pair of electrodes, the nonlocal resistance is defined as

$$R_{nl} = V_{nl}/I. \quad (23)$$

The nonlocal measurement setup differs from the traditional four-probe local measurement, as shown in Fig. 7(b). The traditional four-probe local measurement gives the longitudinal resistivity ρ of the antidot graphene; its dependence on gate voltage for various temperatures is shown in Fig. 7(c). We can see that the charge neutrality

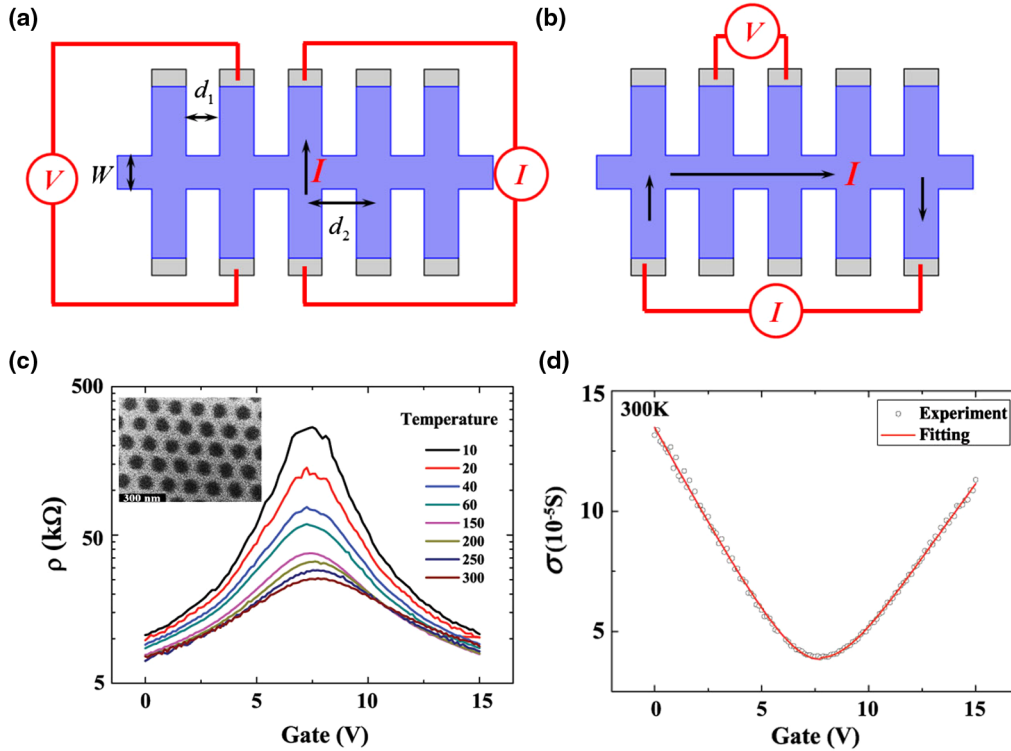


FIG. 7. Measurement setup for (a) nonlocal measurements and (b) local measurements. (c) Antidot graphene resistivity is plotted as a function of gate voltage for various temperatures (from 10 to 300 K). Inset: SEM image for the antidot graphene sample. (d) Room-temperature conductivity as a function of gate voltage is shown to be well fitted by the Boltzmann transport theory, which gives the mobility around $1500 \text{ cm}^2/(\text{Vs})$ and the residue carrier density $n_0 = 2 \times 10^{11}/\text{cm}^2$.

point (CNP) is located around 7.5 V. The longitudinal resistivity has a strong temperature dependence, which can be well described by a variable range hopping model (VRH) [29,51]. The mobility of antidot graphene is usually low compared to pristine graphene [29,52]. The resistivity (conductivity) as a function of gate voltage can be described by $\rho = \rho_s + \left(\sqrt{(CV_g/e)^2 + n_0^2 e \mu} \right)^{-1}$ [29,52–54], where ρ_s comes from the short-range scatterings, μ is the mobility controlled by long-range (charged-impurity) scatterings, C is the capacitance per unit area of SiO₂, and n_0 is the residue carrier density due to the electron-hole puddle effect [55–57]. These parameters can be obtained by fitting the room-temperature data. The fitting details are shown in Fig. 7(d), which gives mobility $\mu = 1500 \text{ cm}^2/(\text{Vs})$ and residue carrier density $n_0 = 2 \times 10^{11}/\text{cm}^2$.

C. Theory on nonlocal transverse conductance and simulations

The nonlocal resistance is determined by the topological current that flows in the sample channel. Since the state has a nonzero Berry curvature, it will result in a transverse conductance σ_{xy} , given by [5,6]

$$\sigma_{xy} = 4 \frac{e^2}{(2\pi)^2 \hbar} \cdot \frac{1}{2} \int \Omega_{11}(k) f(k) dk, \quad (24a)$$

where $k = |\mathbf{k}|$, $f(k)$ is the Fermi distribution function, and the Fermi level is determined by the carrier density n , which is related to k_F by the relation $n = k_F^2/\pi$. Here, the factor $1/2$ comes from the evaluation of effective Berry curvature as shown in Sec. III E. Substituting Eq. (19) into Eq. (24a), we obtain

$$\sigma_{xy} = \frac{e^2}{h} \frac{m/\hbar v}{\sqrt{(m/\hbar v)^2 + \pi n}}. \quad (24b)$$

The nonlocal resistance is strongly related to the transverse conductance and may be expressed as [6,11]

$$R_{nl} = \rho^3 \sigma_{xy}^2 \cdot \alpha = \rho^3 \alpha \frac{e^4}{h^2} \frac{(m/\hbar v)^2}{(m/\hbar v)^2 + \pi n}, \quad (25)$$

where α is a coefficient that is independent of the Fermi energy but depends on the sample geometric parameters, W and d_2 , where W denotes the sample width and d_2 the separation between the electrodes as shown in Fig. 7. Ultimately, the coefficient α is also related to the decay length ξ of the Berry curvature density, as shown below.

An accurate value of α is important for the comparison between the theory prediction and experimental data. To find the behavior of coefficient α , a differential diffusion equation must be solved. We show below that depending on

whether ξ is larger or smaller than the sample width W , different behaviors of α can be derived.

The diffusion equation below was originally formulated to describe spin diffusion, but it can be adapted to describe Berry curvature diffusion [11]:

$$\xi^2 \partial^2 s(x, y) - s(x, y) = \Xi(x, y), \quad (26a)$$

where s is the “Berry curvature” (spin) density. The source term $\Xi(x, y)$ is determined by the external electric field, with a form given by [11]

$$\Xi(x, y) = -\frac{\tau_s I \sigma_{xy} / W \sigma}{\sinh(\pi x / W)} \left[\delta(y - W/2) + \delta(y + W/2) \right]. \quad (26b)$$

Here I denotes the current, and σ_{xy} , σ stand for the transverse and longitudinal conductivities, respectively; τ_s is the relaxation time, which is related to ξ by $\tau_s \sim \xi^2$. The two delta functions in Eq. (26b) indicate that the source term is nonzero only at the two edges ($y = \pm W/2$); hence, Eq. (26b) serves as a boundary condition for $s(x, y)$. The induced Berry curvature current along the x direction is given by $J_s = -(\xi^2/\tau_s) \partial_x \int_{-W/2}^{W/2} dy \cdot s(x, y) = \alpha \cdot I \sigma_{xy} / \sigma$. Here, the quantity ξ^2/τ_s is the intrinsic diffusion constant; it is treated as a constant of the problem. Based on the above definition of the Berry curvature current, we can obtain the nonlocal resistance, given by Eq. (25). In Ref. [11], it is shown that in the range $W \ll \xi$, the coefficient α can be analytically expressed as $\alpha = W \exp(-d_2/\xi)/2\xi$. However, in the regime $W \geq \xi$, the coefficient α has to be solved numerically. The case of small ξ (as compared with W) is crucial here, as the decay length must be quite small in antidot graphene since the mobility is low. Below, we show that by fitting the experimental data, the decay length was found to be on the order of 450–550 nm for our three antidot graphene samples. They are consistently smaller than the decay length (2 μm) reported in graphene placed on top of h-BN [6].

Following the work in Ref. [11], we have obtained the coefficient α by numerically solving the differential diffusion equation [Eq. (26a)] with its boundary conditions [Eq. (26b)], by using the commercial software COMSOL [58] package. The Berry curvature density $s(x, y)$ can be obtained numerically. One simulated example with $\xi = W$ is shown in Fig. 8(a). The color scale indicates the magnitude of the Berry curvature density; its magnitude is seen to decay to zero as x deviates from $x = 0$. The Berry curvature current density, defined as $J_s(x) = -(\xi^2/\tau_s) \partial_x \int_{-W/2}^{W/2} dy \cdot s(x, y)$, is summarized in Fig. 8(b) for various values of ξ . Here, $J_s(x)$ is seen to decay exponentially with x . Hence, the coefficient α should behave as $\alpha \equiv f \exp(-x/\lambda)$, where f and λ are dependent on ξ . Their functional dependencies are shown in Fig. 9(a). In the range $\xi \gg W$, $\lambda = \xi$ and $f = W/2\xi$, our simulations

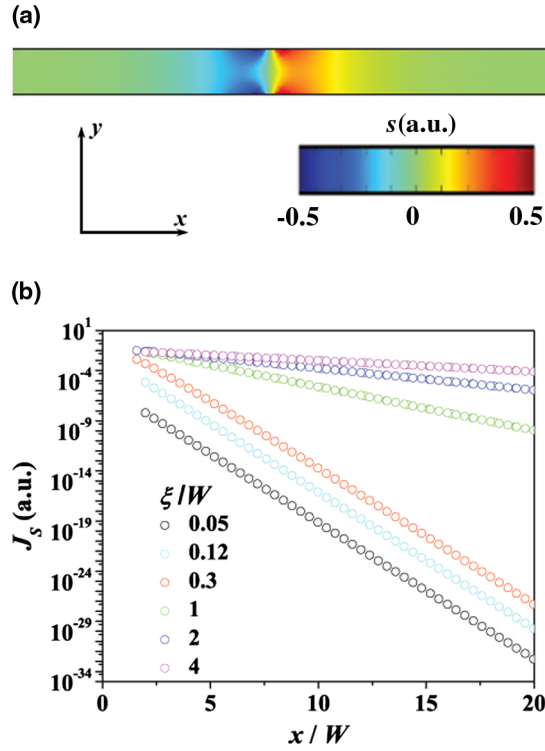


FIG. 8. (a) The distribution of Berry curvature density $s(x, y)$ obtained by simulations using the COMSOL package. The decay length ξ is set to be $\xi = W$. The color indicates the magnitude of the Berry curvature density in arbitrary units. (b) The Berry curvature current density J_S is plotted as a function of x . The cases of $\xi/W = 0.05, 0.12, 0.3, 1, 2, 4$ are shown. In all cases, J_S is seen to decay exponentially with x .

exactly reproduce the analytical expression given previously. However, in the regime $\xi \leq W$, λ saturates at W/π when ξ approaches 0. That means when ξ is small, the nonlocal resistance decays exponentially as $\exp(-\pi x/W)$, instead of $\exp(-x/\xi)$, as previously predicted by the analytical formula. For the parameter f , its value peaks at W/π and decays quickly as ξ decreases. These behaviors clearly imply that the previous analytical expression for α cannot model the properties of the system in the regime $\xi \leq W$. The behavior of the coefficient α , as a function of ξ , is summarized in Fig. 9(b). It is seen that the simulation results deviate from the analytical expression in the small ξ/W range. In the following analysis of the nonlocal resistance, we will use the simulation results in Fig. 9(b).

The exponential decay length has been measured on disordered graphene in Ref. [12], where λ was found to be 300 nm with a sample width of 0.9 μm . The relation between λ and the sample width is noted to agree with what we have predicted here.

D. Simulation of the stray current

In order to isolate the nonzero transverse conductance σ_{xy} , it is necessary to exclude the stray current that can exist

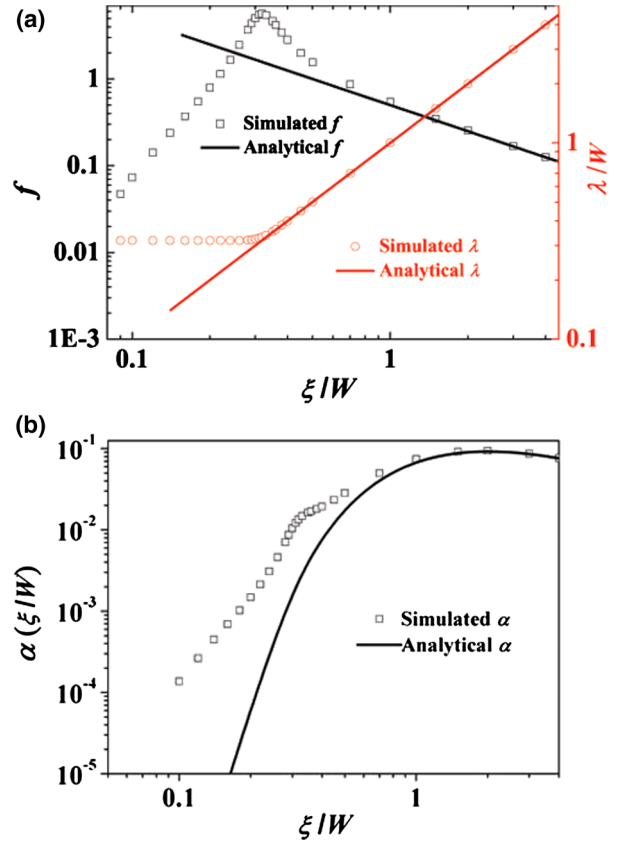


FIG. 9. (a) Parameters f , λ and (b) coefficient $\alpha(\xi)$ are plotted as a function of ξ/W . The open symbols are simulation results, while the solid curves are from the analytical expression given in Ref. [11]. The simulation results and the predictions of the analytical expression agree well in the range $\xi \gg W$, but they differ when $\xi \leq W$. The latter applies to our samples.

even when there is no topological current. Since the voltage-probe electrodes are located on opposite sides of the system [as shown in Fig. 7(a)], a voltage drop between the voltage-probe electrodes is expected once a current flows through the sample. This classical diffusive transport behavior can be understood as the stray current effect, which can be approximated by the van der Pauw relation, i.e., $R'_{nl} \sim \rho \exp(-\pi L/W)$. This effect can also be accurately calculated by COMSOL simulations, which is shown in Fig. 10, where the color indicates the potential distribution. To clearly observe the nonlocal voltage difference (which is quite small), we intentionally focus on the range of 0.45 V and 0.55 V. By analyzing the potential drop between the neighboring Hall electrode pair, we have calculated the nonlocal resistance R'_{nl} that results from the stray current in our system,

$$R'_{nl} = 0.00594\rho, \quad (27)$$

where ρ is the longitudinal resistivity of antidot graphene.

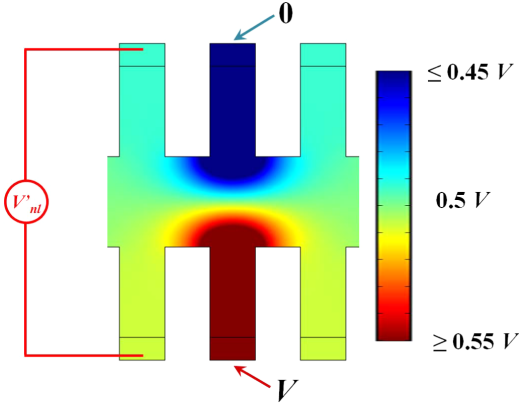


FIG. 10. Stray current effect simulated by COMSOL. A voltage drop V is imposed between the central pair of Hall electrodes. The color scale is in the range of 0.45 V to 0.55 V.

E. Nonlocal resistance from the Berry curvature

For the nonlocal measurements, we find that by using the nearest-neighbor electrode pair for applying current and detecting voltages (with the electrode separation of $4\ \mu\text{m}$), we can always observe a peak at CNP for the nonlocal resistance. However, for electrode pairs of other separations (such as 8 or $12\ \mu\text{m}$), the detected voltage drop is nothing but noise. In Fig. 11, we present the measured nonlocal resistance R_{nl}^{exp} (solid curves obtained from nearest neighbors) as a function of gate voltage at various temperatures. To rule out the stray current effect, we also plot the

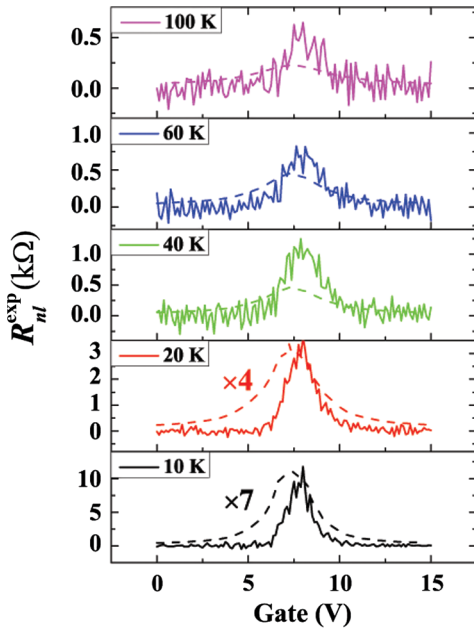


FIG. 11. The measured nonlocal resistance R_{nl}^{exp} is plotted as a function of gate voltage for different temperatures, as shown by the solid curves. The calculated stray current R'_{nl} is shown by dashed curves. The magnitude of R'_{nl} is amplified by a factor of 7 for 10 K and by a factor of 4 for 20 K.

calculated R'_{nl} (dashed curves) in the same figure. For a clearer comparison, the signal of R'_{nl} is amplified by a factor (7 for 10 K and 4 for 20 K) at low temperatures. We can see that the measured nonlocal resistance R_{nl}^{exp} exceeds the stray current effect (R'_{nl}), implying that the measured excess must arise from the topological effect.

We summarize the temperature dependence of the nonlocal resistance in Fig. 12, where the black solid squares represent the peak values (backgate fixed at CNP) of measured nonlocal resistance, and the red solid curve stands for the calculated R'_{nl} . Based on Eqs. (25) and (27), we conclude that the peak values follow the relations $R_{nl} \sim \rho^3$ and $R'_{nl} \sim \rho$. Since $\rho(T)$ near the CNP decreases when the temperature increases [29] [see Fig. 7(c)], R_{nl} decreases faster than R'_{nl} as temperature rises. This is clearly shown in Fig. 12, in which the black dashed curve, representing $R_{nl}(T) + R'_{nl}(T)$, is seen to display a crossover behavior that agrees extremely well with the measured nonlocal resistance of R_{nl}^{exp} . It follows that at high temperatures, R_{nl}^{exp} is dominated by the stray current effect, whereas at low temperatures, the topological nonlocal resistance dominates. For $T < 100$ K, the measured nonlocal resistance is larger than what is expected from the stray current effect. This means that for $T < 100$ K, the topological current can induce a detectable nonlocal voltage drop. We define the topological nonlocal resistance as $R_{nl} \equiv R_{nl}^{\text{exp}} - R'_{nl}$. It is shown below that the carrier concentration dependence of this nonlocal resistance can be well predicted by Eq. (28).

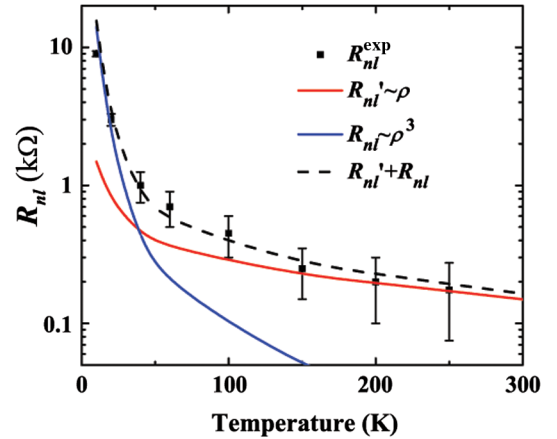


FIG. 12. The peak values (at CNP) of measured nonlocal resistance are plotted as a function of temperature, shown as black solid squares. The calculated stray current effect $R'_{nl} \propto \rho(T)$ is shown by the solid red curve. The blue curve denotes the peak values of topological nonlocal resistance calculated, $R_{nl} \propto \rho^3(T)$, based on Eq. (28) for a fixed $\xi = 450$ nm. The black dashed curve represents $R_{nl} + R'_{nl}$. It is clear that there is a crossover from the high-temperature, linear $\rho(T)$ behavior to the low-temperature, $\rho^3(T)$ behavior. The measured data are seen to agree with this crossover behavior (dashed curve) extremely well.

Apart from the magnitude, there is also a difference between the features of the measured nonlocal resistance R_{nl}^{exp} and the stray current-induced R'_{nl} . For the low-temperature data (10 K and 20 K), the measured nonlocal resistance is zero for $|V - V_{\text{CNP}}| > 2$ V as shown in Fig. 11. For the stray current effect (dashed curves), its values decay to zero smoothly.

V. COMPARISON BETWEEN THEORY AND EXPERIMENT

In Fig. 13, we plot the topological nonlocal resistance, $R_{nl} = R_{nl}^{\text{exp}} - R'_{nl}$, as a function of carrier density (open circles). The measured data can be well fitted by the following equation,

$$R_{nl} = \rho^3 \left(\frac{e^2}{h} \right)^2 \frac{(m/\hbar v)^2}{(m/\hbar v)^2 + \pi \sqrt{n^2 + n_0^2}} \cdot \alpha(\xi), \quad (28)$$

where the term n in Eq. (25) is replaced by $\sqrt{n^2 + n_0^2}$, with $n_0 = 2 \times 10^{11}/\text{cm}^{-2}$ being the residue carrier density at CNP. Since $m/\hbar v \approx 0.03 \text{ nm}^{-1}$ is known from the tight-binding calculations, the fitting requires just one parameter—the decay length ξ . The best fit gives $\xi \approx 450 \text{ nm}$. Note that this value is indeed much smaller than the sample width $W = 2 \text{ }\mu\text{m}$.

The small decay length values in our samples, as compared to that reported in Ref. [6], can be attributed

to the fact that our graphene samples are nanostructured and placed on top of SiO_2 , while in Ref. [6] the sample is pristine graphene placed on h-BN substrate. The latter has been shown to be a much cleaner and flatter substrate [59]. In our samples, the magnitude of the residue carrier density is on the order of $10^{11}/\text{cm}^2$, much larger than that for pristine graphene on h-BN, which is on the order of $10^{10}/\text{cm}^2$. It follows that our samples are more disordered, and therefore, they can have a much shorter scattering time τ_s . Since $\xi \propto \sqrt{\tau_s}$, a short decay length follows.

Based on the decay length $\xi \approx 450 \text{ nm}$, it is easy to understand why we cannot detect the nonlocal voltage drop for the next-nearest neighbor electrode pairs (with a separation of $8 \text{ }\mu\text{m}$). Since the magnitude of nonlocal voltage drop is determined by the coefficient $\alpha(\xi, x)$, defined as $\alpha \equiv f(\xi) \exp(-\pi x/W)$. For the nearest-neighbor electrode pairs, $x = 4 \text{ }\mu\text{m}$, which gives $\exp(-\pi x/W) = 1.8 \times 10^{-3}$. However, for the next-nearest-neighbor electrode, $x = 8 \text{ }\mu\text{m}$, which yields $\exp(-\pi x/W) = 3.5 \times 10^{-6}$. Consider the data at 10 K (see Fig. 11); for $x = 4 \text{ }\mu\text{m}$, the peak of nonlocal resistance is about $10 \text{ k}\Omega$. Based on this value, for $x = 8 \text{ }\mu\text{m}$, the peak value of the nonlocal resistance is estimated to be on the order of $10 \text{ }\Omega$, which is below the noise floor.

The nonlocal resistance as a function of carrier density measured at 10 K for samples B and C are summarized in Fig. 14. In the upper panel, red open circles show the nonlocal resistance measured from sample B, and the inset is its SEM image. In the bottom panel, similar results for sample C are summarized. To fit these nonlocal resistance data, we follow the steps of analyzing sample A as presented above. We first

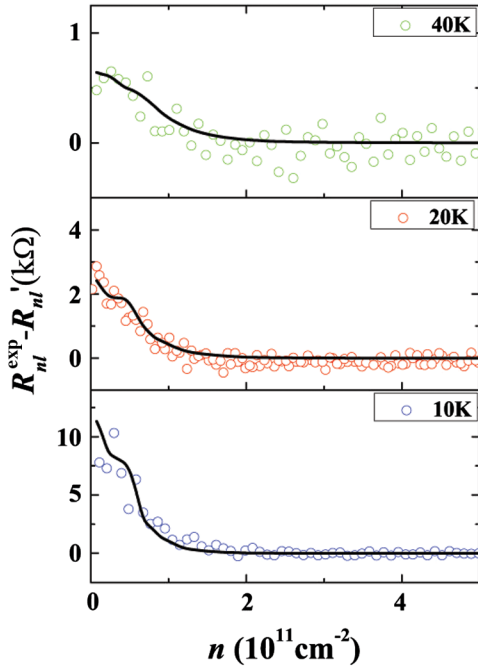


FIG. 13. The topological nonlocal resistance (defined as $R_{nl}^{\text{exp}} - R'_{nl}$) is plotted as a function of carrier density, shown by open circles at temperatures of 10, 20, and 40 K. The fitted nonlocal resistance is shown by the solid black curves. This fitting yields a value for the decay length ξ of 450 nm.

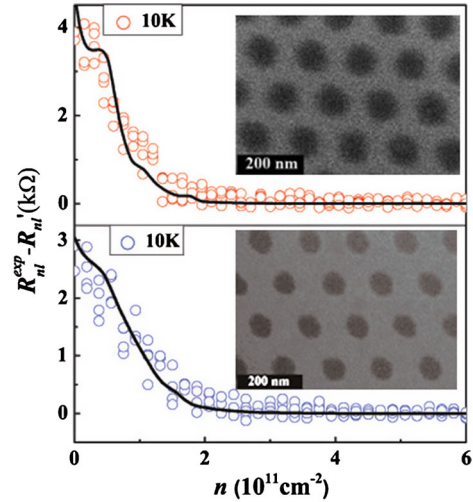


FIG. 14. The topological nonlocal resistance (defined as $R_{nl}^{\text{exp}} - R'_{nl}$) is plotted as a function of carrier density for sample B (upper panel), with a designed hole diameter of 80 nm, and sample C (bottom panel), with a designed hole diameter of 60 nm, shown by open circles for different samples with different geometric factors. The periodicity is fixed at 150 nm. The solid curves represent the fitted nonlocal resistance.

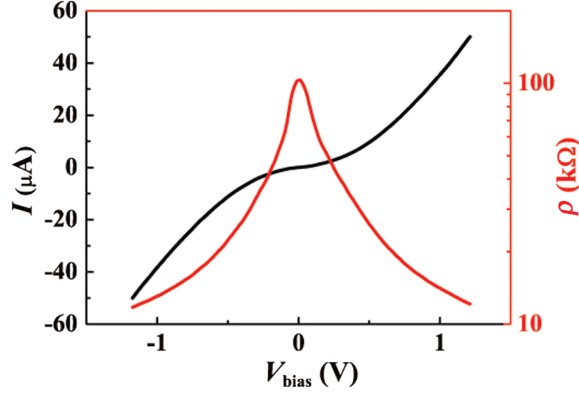


FIG. 15. The black curves represent the I-V curve at 10 K for sample C. The red curve is the derived resistance per square. The resistance at small bias voltage is around 100 kΩ, which is much larger than h/e^2 . Hence, the existence of a conducting edge state is not likely.

calculate the parameter $m/\hbar v$ (based on tight-binding calculations) and the residue carrier density n_0 (based on experimental resistivity-back gate curves). For sample B, we have $m/\hbar v = 0.021 \text{ nm}^{-1}$ and $n_0 = 2.2 \times 10^{11}/\text{cm}^{-2}$; for sample C, we have $m/\hbar v = 0.015 \text{ nm}^{-1}$ and $n_0 = 1.3 \times 10^{11}/\text{cm}^{-2}$. With these input values, we fit the experimental nonlocal resistance data, shown by the black solid curves in Fig. 14. These fittings yield the decay length $\xi \approx 500 \text{ nm}$ for sample B and $\xi \approx 550 \text{ nm}$ for sample C. It is also noted that as the diameters of the holes decrease, the signal of nonlocal resistance is reduced, due to the decrease of ρ .

A recent experimental work [60] demonstrated that a conducting edge state might exist in gapped bilayer graphene. Can such a conducting edge state exist in our sample? For our antidot graphene samples placed on top of SiO_2 , the evidence seems to indicate that there cannot be a conducting edge-state channel since the existence of such a state should enhance the measured transverse nonlocal resistance, and over a longer distance, e.g., over $8 \mu\text{m}$. These were not seen. More conclusively, we have measured the I-V curve of sample C at 10 K with gate voltage fixed at CNP. The I-V curve is shown in Fig. 15. The non-linear behavior of the I-V curve indicates the existence of a gap in antidot graphene. From the I-V curve, the derived

resistance per square as a function of bias voltage is also plotted. Note that the resistance at CNP (measured under a small bias voltage) is around a few hundred kilo Ohms, which is much larger than the edge-state channel where the resistance should be on the order of $h/e^2 \sim 25.9 \text{ kilo Ohms}$. Thus, the existence of a conducting edge state is highly unlikely.

VI. CONCLUSIONS

In this work, we have obtained the effective Hamiltonian of antidot graphene based on the tight-binding eigenvalues and eigenfunctions. The effective Hamiltonian predicts the gap opening at the Dirac point due to intervalley scatterings. Based on the effective Hamiltonian, we find the Berry curvature to be nonzero, without breaking either the time-reversal or inversion symmetry. The nonzero Berry curvature can be experimentally verified by nonlocal transport measurements, based on three separately fabricated antidot graphene samples. The very good one-parameter fitting of the nonlocal resistance data gives the topological current decay length of $\xi = 450, 500, \text{ and } 550 \text{ nm}$ for three samples with fixed periodicity of 150 nm and hole diameters of $100, 80, \text{ and } 60 \text{ nm}$, respectively.

ACKNOWLEDGMENTS

Research support by Hong Kong Research Grant Council GRF Grants No. 16304314 and No. 16307114 is hereby gratefully acknowledged. P. S. also wishes to thank Steven Louie and C. T. Chan for helpful discussions.

APPENDIX A: PROOF OF TIME-REVERSAL SYMMETRY RELATION BETWEEN DOUBLE DEGENERATE STATES

By definition, under time-reversal transformation, the momentum $\mathbf{k}$ flips signs, and the wave function takes its complex conjugate, that is,

$$\mathcal{T}\psi_2(\mathbf{k}) = \psi_2(-\mathbf{k})^*. \quad (\text{A1})$$

We want to show that

$$\psi_2(-\mathbf{k})^* = e^{i\theta} \cdot \psi_1(\mathbf{k}). \quad (\text{A2})$$

This can be achieved in the following two steps.

- (1) By recalling that $\psi_2(\mathbf{k}) = \left\{ -[(ke^{-i\theta})/\sqrt{\epsilon-m}] \quad -\sqrt{\epsilon-m} \quad \sqrt{\epsilon-m} \quad -[(ke^{-i\theta})/\sqrt{\epsilon-m}] \right\}^T / 2\sqrt{\epsilon}$, where the four components correspond to KA, KB, K'A, K'B. By flipping the sign of $\mathbf{k}$, we must remember that we are changing the total momentum of $(K + \mathbf{k})$ to $-(K + \mathbf{k})$. Since $-K = K'$, it follows that changing the sign of $\mathbf{k}$ is always accompanied by exchanging the K and K' valleys. Hence, KA becomes K'A and KB becomes K'B, and vice versa. Therefore, we have

$$\psi_2(-\mathbf{k}) = \left(\sqrt{\epsilon-m} \quad \frac{ke^{-i\theta}}{\sqrt{\epsilon-m}} \quad \frac{ke^{-i\theta}}{\sqrt{\epsilon-m}} \quad -\sqrt{\epsilon-m} \right)^T / 2\sqrt{\epsilon}. \quad (\text{A3})$$

(2) It is straightforward to obtain

$$\psi_2(-\mathbf{k})^* = \left(\sqrt{\varepsilon - m} \quad \frac{ke^{+i\theta}}{\sqrt{\varepsilon - m}} \quad \frac{ke^{+i\theta}}{\sqrt{\varepsilon - m}} \quad -\sqrt{\varepsilon - m} \right)^T / 2\sqrt{\varepsilon}. \quad (\text{A4})$$

Since $\psi_1(\mathbf{k}) = \left\{ [(ke^{-i\theta})/\sqrt{\varepsilon + m}] \sqrt{\varepsilon + m} \sqrt{\varepsilon + m} - [(ke^{-i\theta})/\sqrt{\varepsilon + m}]^T / 2\sqrt{\varepsilon} \right\}$ and $k = \sqrt{\varepsilon^2 - m^2} = \sqrt{\varepsilon + m} \cdot \sqrt{\varepsilon - m}$, it follows that

$$\begin{aligned} e^{i\theta}\psi_1(\mathbf{k}) &= \left(\frac{k}{\sqrt{\varepsilon + m}} \quad \sqrt{\varepsilon + m}e^{i\theta} \quad \sqrt{\varepsilon + m}e^{i\theta} \quad -\frac{k}{\sqrt{\varepsilon + m}} \right)^T / 2\sqrt{\varepsilon} \\ &= \left(\sqrt{\varepsilon - m} \quad \frac{k}{\sqrt{\varepsilon - m}}e^{i\theta} \quad \frac{k}{\sqrt{\varepsilon - m}}e^{i\theta} \quad -\sqrt{\varepsilon - m} \right)^T / 2\sqrt{\varepsilon} \\ &= \psi_2(-\mathbf{k})^*. \end{aligned} \quad (\text{A5})$$

Therefore, $T\psi_2(\mathbf{k}) = \psi_2(-\mathbf{k})^* = e^{i\theta} \cdot \psi_1(\mathbf{k})$.

APPENDIX B: PROOF OF $\Omega_2(-\mathbf{k}) = -\Omega_1(\mathbf{k})$

To prove $\Omega_2(-\mathbf{k}) = -\Omega_1(\mathbf{k})$, i.e., Eq. (14), we start from the definition of Berry curvature,

$$\Omega_1 = i(\langle \partial_{k_x}\psi_1 | \partial_{k_y}\psi_1 \rangle - \langle \partial_{k_y}\psi_1 | \partial_{k_x}\psi_1 \rangle) = i \left(\int \partial_{k_x}(\psi_1^*) \partial_{k_y}\psi_1 d\mathbf{r} - \int \partial_{k_y}(\psi_1^*) \partial_{k_x}\psi_1 d\mathbf{r} \right), \quad (\text{B1})$$

where $\psi_1 = \psi_1(k, \mathbf{r})$, with $\mathbf{r} = (x, y)$. The proof can also be divided into two steps.

(1) We first show that the additional phase $\exp(i\theta)$ does not change the Berry curvature.

By replacing ψ_1 in Eq. (B1) with $\psi_1 e^{i\theta}$, the term in the bracket becomes

$$\begin{aligned} & \int \partial_{k_x}((\psi_1 e^{i\theta})^*) \partial_{k_y}(\psi_1 e^{i\theta}) d\mathbf{r} - \int \partial_{k_y}((\psi_1 e^{i\theta})^*) \partial_{k_x}(\psi_1 e^{i\theta}) d\mathbf{r} \\ &= \int \partial_{k_x}(\psi_1^*) \partial_{k_y}\psi_1 d\mathbf{r} + \int \psi_1^* \psi_1 \partial_{k_x}\theta \cdot \partial_{k_y}\theta d\mathbf{r} + i \int (\psi_1 \partial_{k_x}\psi_1^* \partial_{k_y}\theta - \psi_1^* \partial_{k_y}\psi_1 \partial_{k_x}\theta) d\mathbf{r} \\ & \quad - \left[\int \partial_{k_y}(\psi_1^*) \partial_{k_x}\psi_1 d\mathbf{r} + \int \psi_1^* \psi_1 \partial_{k_y}\theta \cdot \partial_{k_x}\theta d\mathbf{r} + i \int (\psi_1 \partial_{k_y}\psi_1^* \partial_{k_x}\theta - \psi_1^* \partial_{k_x}\psi_1 \partial_{k_y}\theta) d\mathbf{r} \right] \\ &= \int \partial_{k_x}(\psi_1^*) \partial_{k_y}\psi_1 d\mathbf{r} + i \int (\psi_1 \partial_{k_x}\psi_1^* \partial_{k_y}\theta - \psi_1^* \partial_{k_y}\psi_1 \partial_{k_x}\theta) d\mathbf{r} \\ & \quad - \left[\int \partial_{k_y}(\psi_1^*) \partial_{k_x}\psi_1 d\mathbf{r} + i \int (\psi_1 \partial_{k_y}\psi_1^* \partial_{k_x}\theta - \psi_1^* \partial_{k_x}\psi_1 \partial_{k_y}\theta) d\mathbf{r} \right] \\ &= \int \partial_{k_x}(\psi_1^*) \partial_{k_y}\psi_1 d\mathbf{r} - \int \partial_{k_y}(\psi_1^*) \partial_{k_x}\psi_1 d\mathbf{r} \\ & \quad + i \left[\int (\psi_1 \partial_{k_x}\psi_1^* \partial_{k_y}\theta + \psi_1^* \partial_{k_x}\psi_1 \partial_{k_y}\theta) d\mathbf{r} - \int (\psi_1 \partial_{k_y}\psi_1^* \partial_{k_x}\theta + \psi_1^* \partial_{k_y}\psi_1 \partial_{k_x}\theta) d\mathbf{r} \right] \\ &= \int \partial_{k_x}(\psi_1^*) \partial_{k_y}\psi_1 d\mathbf{r} - \int \partial_{k_y}(\psi_1^*) \partial_{k_x}\psi_1 d\mathbf{r} \\ & \quad + i \left[\partial_{k_y}\theta \cdot \partial_{k_x} \int (\psi_1^* \psi_1) d\mathbf{r} - \partial_{k_x}\theta \cdot \partial_{k_y} \int (\psi_1^* \psi_1) d\mathbf{r} \right] \\ &= \int \partial_{k_x}(\psi_1^*) \partial_{k_y}\psi_1 d\mathbf{r} - \int \partial_{k_y}(\psi_1^*) \partial_{k_x}\psi_1 d\mathbf{r}. \end{aligned}$$

The last step is obvious because the integrated modulus of the wave function is a constant. Therefore, we have

$$\begin{aligned}
& i \left(\int \partial_{k_x} ((\psi_1 e^{i\theta})^*) \partial_{k_y} (\psi_1 e^{i\theta}) d\mathbf{r} - \int \partial_{k_y} ((\psi_1 e^{i\theta})^*) \partial_{k_x} (\psi_1 e^{i\theta}) d\mathbf{r} \right) \\
& = i \left(\int \partial_{k_x} (\psi_1^*) \partial_{k_y} \psi_1 d\mathbf{r} - \int \partial_{k_y} (\psi_1^*) \partial_{k_x} \psi_1 d\mathbf{r} \right) = \Omega_1(\mathbf{k}).
\end{aligned} \tag{B2}$$

Hence, we conclude that the additional phase does not change the Berry curvature.

(2) Replace $\psi_1 e^{i\theta}$ by $\psi_2(-\mathbf{k})^*$.

According to the conclusion of Appendix A, we have $\psi_1 e^{i\theta} = \psi_2(-\mathbf{k})^*$.

Therefore,

$$\begin{aligned}
\Omega_1(\mathbf{k}) & = i \left(\int \partial_{k_x} ((\psi_1 e^{i\theta})^*) \partial_{k_y} (\psi_1 e^{i\theta}) d\mathbf{r} - \int \partial_{k_y} ((\psi_1 e^{i\theta})^*) \partial_{k_x} (\psi_1 e^{i\theta}) d\mathbf{r} \right) \\
& = i \left(\int \partial_{k_x} \psi_2(-\mathbf{k}) \cdot \partial_{k_y} \psi_2(-\mathbf{k})^* d\mathbf{r} - \int \partial_{k_y} \psi_2(-\mathbf{k}) \cdot \partial_{k_x} \psi_2(-\mathbf{k})^* d\mathbf{r} \right) \\
& = -i \left(\int \partial_{k_x} \psi_2(-\mathbf{k})^* \cdot \partial_{k_y} \psi_2(-\mathbf{k}) d\mathbf{r} - \int \partial_{k_x} \psi_2(-\mathbf{k}) \cdot \partial_{k_y} \psi_2(-\mathbf{k})^* d\mathbf{r} \right) \\
& = -\Omega_2(-\mathbf{k}).
\end{aligned}$$

-
- [1] K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, Y. Zhang, S. V. Dubonos, I. V. Grigorieva, and A. A. Firsov, *Electric Field Effect in Atomically Thin Carbon Films*, *Science* **306**, 666 (2004).
- [2] K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, M. I. Katsnelson, I. V. Grigorieva, S. V. Dubonos, and A. A. Firsov, *Two-Dimensional Gas of Massless Dirac Fermions in Graphene*, *Nature (London)* **438**, 197 (2005).
- [3] Y. B. Zhang, Y. W. Tan, H. L. Stormer, and P. Kim, *Experimental Observation of the Quantum Hall Effect and Berry's Phase in Graphene*, *Nature (London)* **438**, 201 (2005).
- [4] A. K. Geim and K. S. Novoselov, *The Rise of Graphene*, *Nat. Mater.* **6**, 183 (2007).
- [5] D. Xiao, W. Yao, and Q. Niu, *Valley-Contrasting Physics in Graphene: Magnetic Moment and Topological Transport*, *Phys. Rev. Lett.* **99**, 236809 (2007).
- [6] R. V. Gorbachev *et al.*, *Detecting Topological Currents in Graphene Superlattices*, *Science* **346**, 448 (2014).
- [7] M. Q. Sui *et al.*, *Gate-Tunable Topological Valley Transport in Bilayer Graphene*, *Nat. Phys.* **11**, 1027 (2015).
- [8] Y. Shimazaki, M. Yamamoto, I. V. Borzenets, K. Watanabe, T. Taniguchi, and S. Tarucha, *Generation and Detection of Pure Valley Current by Electrically Induced Berry Curvature in Bilayer Graphene*, *Nat. Phys.* **11**, 1032 (2015).
- [9] D. Xiao, M. C. Chang, and Q. Niu, *Berry Phase Effects on Electronic Properties*, *Rev. Mod. Phys.* **82**, 1959 (2010).
- [10] Y. D. Lensky, J. C. W. Song, P. Samutpraphoot, and L. S. Levitov, *Topological Valley Currents in Gapped Dirac Materials*, *Phys. Rev. Lett.* **114**, 256601 (2015).
- [11] D. A. Abanin, A. V. Shytov, L. S. Levitov, and B. I. Halperin, *Nonlocal Charge Transport Mediated by Spin Diffusion in the Spin Hall Effect Regime*, *Phys. Rev. B* **79**, 035304 (2009).
- [12] Y. L. Wang, X. H. Cai, J. Reutt-Robey, and M. S. Fuhrer, *Neutral-Current Hall Effects in Disordered Graphene*, *Phys. Rev. B* **92**, 161411 (2015).
- [13] A. A. Kaverzin and B. J. van Wees, *Electron Transport Nonlocality in Monolayer Graphene Modified with Hydrogen Silsesquioxane Polymerization*, *Phys. Rev. B* **91**, 165412 (2015).
- [14] J. Lee, K. F. Mak, and J. Shan, *Electrical Control of the Valley Hall Effect in Bilayer MoS₂ Transistors*, *Nat. Nanotechnol.* **11**, 421 (2016).
- [15] X. L. Li, X. R. Wang, L. Zhang, S. W. Lee, and H. J. Dai, *Chemically Derived, Ultrasoft Graphene Nanoribbon Semiconductors*, *Science* **319**, 1229 (2008).
- [16] X. R. Wang, Y. J. Ouyang, X. L. Li, H. L. Wang, J. Guo, and H. J. Dai, *Room-Temperature All-Semiconducting Sub-10-nm Graphene Nanoribbon Field-Effect Transistors*, *Phys. Rev. Lett.* **100**, 206803 (2008).
- [17] D. V. Kosynkin, A. L. Higginbotham, A. Sinitskii, J. R. Lomeda, A. Dimiev, B. K. Price, and J. M. Tour, *Longitudinal Unzipping of Carbon Nanotubes to Form Graphene Nanoribbons*, *Nature (London)* **458**, 872 (2009).
- [18] Y.-W. Son, M. L. Cohen, and S. G. Louie, *Energy Gaps in Graphene Nanoribbons*, *Phys. Rev. Lett.* **97**, 216803 (2006).
- [19] T. G. Pedersen, C. Flindt, J. Pedersen, N. A. Mortensen, A.-P. Jauho, and K. Pedersen, *Graphene Antidot Lattices: Designed Defects and Spin Qubits*, *Phys. Rev. Lett.* **100**, 136804 (2008).
- [20] J. A. Fürst, J. G. Pedersen, C. Flindt, N. A. Mortensen, M. Brandbyge, T. G. Pedersen, and A. P. Jauho, *Electronic Properties of Graphene Antidot Lattices*, *New J. Phys.* **11**, 095020 (2009).
- [21] J. A. Fürst, T. G. Pedersen, M. Brandbyge, and A.-P. Jauho, *Density Functional Study of Graphene Antidot Lattices:*

- Roles of Geometrical Relaxation and Spin*, *Phys. Rev. B* **80**, 115117 (2009).
- [22] R. Petersen, T. G. Pedersen, and A.-P. Jauho, *Clar Sextet Analysis of Triangular, Rectangular, and Honeycomb Graphene Antidot Lattices*, *ACS Nano* **5**, 523 (2011).
- [23] A. Zhang, H. F. Teoh, Z. Dai, Y. P. Feng, and C. Zhang, *Band Gap Engineering in Graphene and Hexagonal BN Antidot Lattices: A First Principles Study*, *Appl. Phys. Lett.* **98**, 023105 (2011).
- [24] S. Yuan, R. Roldán, A.-P. Jauho, and M. I. Katsnelson, *Electronic Properties of Disordered Graphene Antidot Lattices*, *Phys. Rev. B* **87**, 085430 (2013).
- [25] M. Dvorak, W. Oswald, and Z. G. Wu, *Bandgap Opening by Patterning Graphene*, *Sci. Rep.* **3**, 2289 (2013).
- [26] F. Guinea and T. Low, *Band Structure and Gaps of Triangular Graphene Superlattices*, *Phil. Trans. R. Soc. A* **368**, 5391 (2010).
- [27] J. Eroms and D. Weiss, *Weak Localization and Transport Gap in Graphene Antidot Lattices*, *New J. Phys.* **11**, 095021 (2009).
- [28] A. J. M. Giesbers, E. C. Peters, M. Burghard, and K. Kern, *Charge Transport Gap in Graphene Antidot Lattices*, *Phys. Rev. B* **86**, 045445 (2012).
- [29] H. Zhang *et al.*, *Large-Scale Mesoscopic Transport in Nanostructured Graphene*, *Phys. Rev. Lett.* **110**, 066805 (2013).
- [30] E. C. Peters, A. J. M. Giesbers, U. Zeitler, M. Burghard, and K. Kern, *Valley-Polarized Massive Charge Carriers in Gapped Graphene*, *Phys. Rev. B* **87**, 201403 (2013).
- [31] R. Yagi, R. Sakakibara, R. Ebisuoka, J. Onishi, K. Watanabe, T. Taniguchi, and Y. Iye, *Ballistic Transport in Graphene Antidot Lattices*, *Phys. Rev. B* **92**, 195406 (2015).
- [32] A. Sandner, T. Preis, C. Schell, P. Giudici, K. Watanabe, T. Taniguchi, D. Weiss, and J. Eroms, *Ballistic Transport in Graphene Antidot Lattices*, *Nano Lett.* **15**, 8402 (2015).
- [33] S. R. Power and A. P. Jauho, *Electronic Transport in Disordered Graphene Antidot Lattice Devices*, *Phys. Rev. B* **90**, 115408 (2014).
- [34] Z. Y. Fan, A. Uppstu, and A. Harju, *Electronic and Transport Properties in Geometrically Disordered Graphene Antidot Lattices*, *Phys. Rev. B* **91**, 125434 (2015).
- [35] M. V. Berry, *Quantal Phase Factors Accompanying Adiabatic Changes*, *Proc. R. Soc. A* **392**, 45 (1984).
- [36] J. G. Pedersen, T. Gunst, T. Markussen, and T. G. Pedersen, *Graphene Antidot Lattice Waveguides*, *Phys. Rev. B* **86**, 245410 (2012).
- [37] J. G. Pedersen, M. H. Brynildsen, H. D. Cornean, and T. G. Pedersen, *Optical Hall Conductivity in Bulk and Nanostructured Graphene Beyond the Dirac Approximation*, *Phys. Rev. B* **86**, 235438 (2012).
- [38] J. G. Pedersen and T. G. Pedersen, *Dirac Model of an Isolated Graphene Antidot in a Magnetic Field*, *Phys. Rev. B* **85**, 035413 (2012).
- [39] T. Ando, *Theory of Valley Hall Conductivity in Graphene with Gap*, *J. Phys. Soc. Jpn.* **84**, 114705 (2015).
- [40] L. Jiang, Y. Zheng, H. Li, and H. Shen, *Magneto-Transport Properties of Gapped Graphene*, *Nanotechnology* **21**, 145703 (2010).
- [41] M. C. Chang and Q. Niu, *Berry Phase, Hyperorbits, and the Hofstadter Spectrum*, *Phys. Rev. Lett.* **75**, 1348 (1995).
- [42] R. Shindou and K. I. Imura, *Noncommutative Geometry and Non-Abelian Berry Phase in the Wave-Packet Dynamics of Bloch Electrons*, *Nucl. Phys. B* **720**, 399 (2005).
- [43] M. Vanević, V. M. Stojanović, and M. Kindermann, *Character of Electronic States in Graphene Antidot Lattices: Flat Bands and Spatial Localization*, *Phys. Rev. B* **80**, 045410 (2009).
- [44] When introducing the vector potential (magnetic field) to this new 4×4 matrix Hamiltonian, it is easy to show that the Landau Level (LL) is given by $\epsilon_n = \pm\sqrt{m^2 + 2n\hbar Bv^2}$. This implies that the $n = 0$ LL is split into $\epsilon_n = \pm m$. This may be the explanation for the observed zero σ_{xy} plateau in the quantum Hall effect of antidot graphene as reported in Ref. [30].
- [45] H. Nishi, Y. I. Matsushita, and A. Oshiyama, *Band-Unfolding Approach to Moire-Induced Band-Gap Opening and Fermi Level Velocity Reduction in Twisted Bilayer Graphene*, *Phys. Rev. B* **95**, 085420 (2017).
- [46] R. Petersen and T. G. Pedersen, *Quasiparticle Properties of Graphene Antidot Lattices*, *Phys. Rev. B* **80**, 113404 (2009).
- [47] D. Culcer, Y. Yao, and Q. Niu, *Coherent Wave-Packet Evolution in Coupled Bands*, *Phys. Rev. B* **72**, 085110 (2005).
- [48] M. Gradhand, D. V. Fedorov, F. Pientka, P. Zahn, I. Mertig, and B. L. Gyorffy, *First-Principle Calculations of the Berry Curvature of Bloch States for Charge and Spin Transport of Electrons*, *J. Phys. Condens. Matter* **24**, 213202 (2012).
- [49] F. Wilczek and A. Zee, *Appearance of Gauge Structure in Simple Dynamical Systems*, *Phys. Rev. Lett.* **52**, 2111 (1984).
- [50] C. W. Groth, M. Wimmer, A. R. Akhmerov, and X. Waintal, *KWANT: A Software Package for Quantum Transport*, *New J. Phys.* **16**, 063065 (2014).
- [51] E. C. Peters, A. J. M. Giesbers, and M. Burghard, *Variable Range Hopping in Graphene Antidot Lattices*, *Phys. Status Solidi B* **249**, 2522 (2012).
- [52] J. Pan, H. Zhang, Y. Zheng, B. Zhang, T. Zhang, and P. Sheng, *Spatial Variation of Charge Carrier Density in Graphene under a Large Bias Current*, *Phys. Rev. B* **93**, 115424 (2016).
- [53] S. Adam, E. H. Hwang, V. M. Galitski, and S. Das Sarma, *A Self-Consistent Theory for Graphene Transport*, *Proc. Natl. Acad. Sci. U.S.A.* **104**, 18392 (2007).
- [54] S. D. Sarma, S. Adam, E. H. Hwang, and E. Rossi, *Electronic Transport in Two-Dimensional Graphene*, *Rev. Mod. Phys.* **83**, 407 (2011).
- [55] J. Martin, N. Akerman, G. Ulbricht, T. Lohmann, J. H. Smet, K. Von Klitzing, and A. Yacoby, *Observation of Electron-Hole Puddles in Graphene Using a Scanning Single-Electron Transistor*, *Nat. Phys.* **4**, 144 (2008).
- [56] A. H. Castro Neto, F. Guinea, N. M. R. Peres, K. S. Novoselov, and A. K. Geim, *The Electronic Properties of Graphene*, *Rev. Mod. Phys.* **81**, 109 (2009).
- [57] K. Eun-Ah and A. H. C. Neto, *Graphene as an Electronic Membrane*, *Europhys. Lett.* **84**, 57007 (2008).
- [58] See <https://www.comsol.com>.
- [59] C. R. Dean *et al.*, *Boron Nitride Substrates for High-Quality Graphene Electronics*, *Nat. Nanotechnol.* **5**, 722 (2010).
- [60] M. J. Zhu *et al.*, *Edge Currents Shunt the Insulating Bulk in Gapped Graphene*, *Nat. Commun.* **8**, 14552 (2017).